

Fig. 1

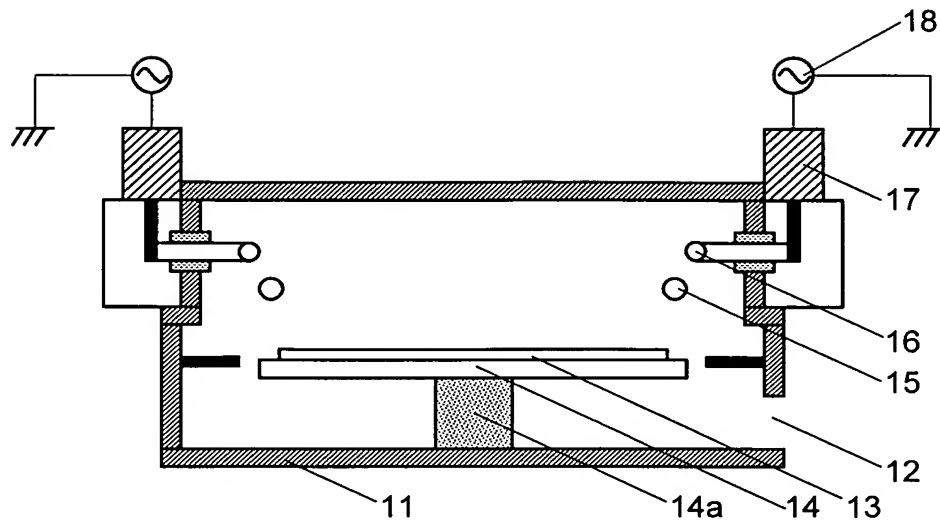


Fig. 2

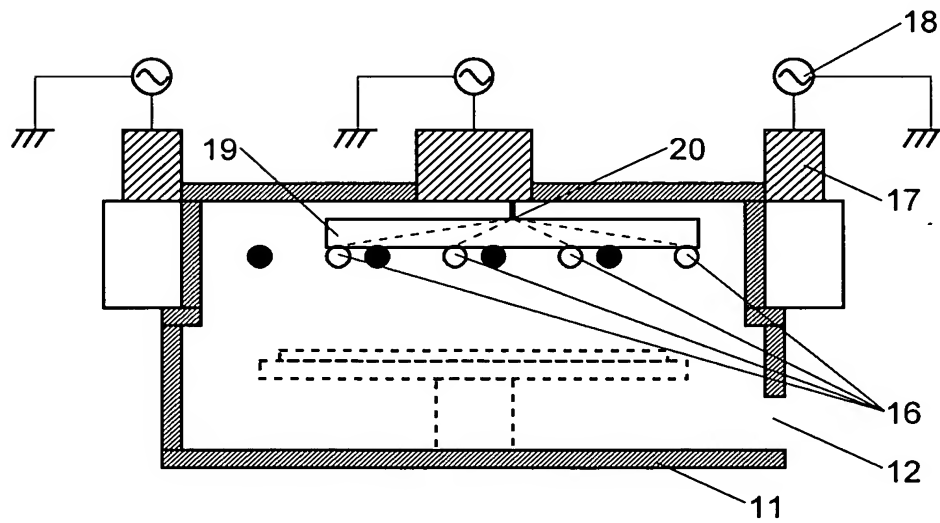


Fig. 4A

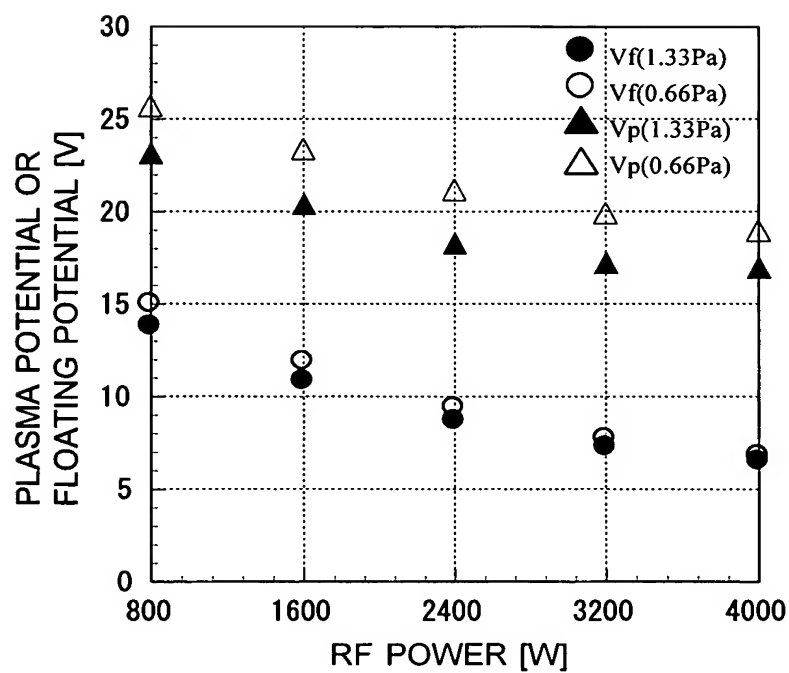


Fig. 4B

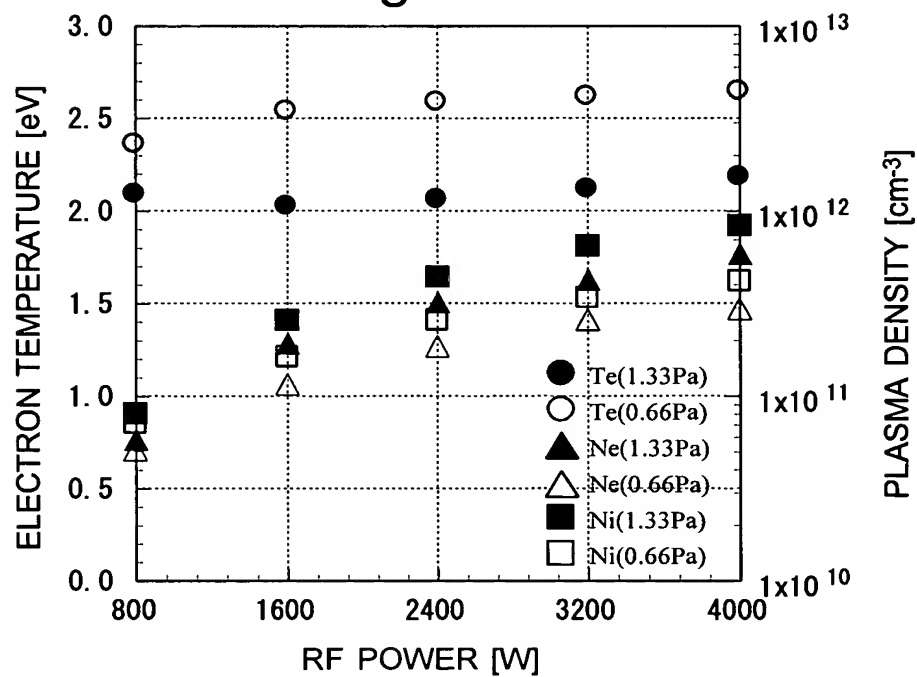


Fig. 5A

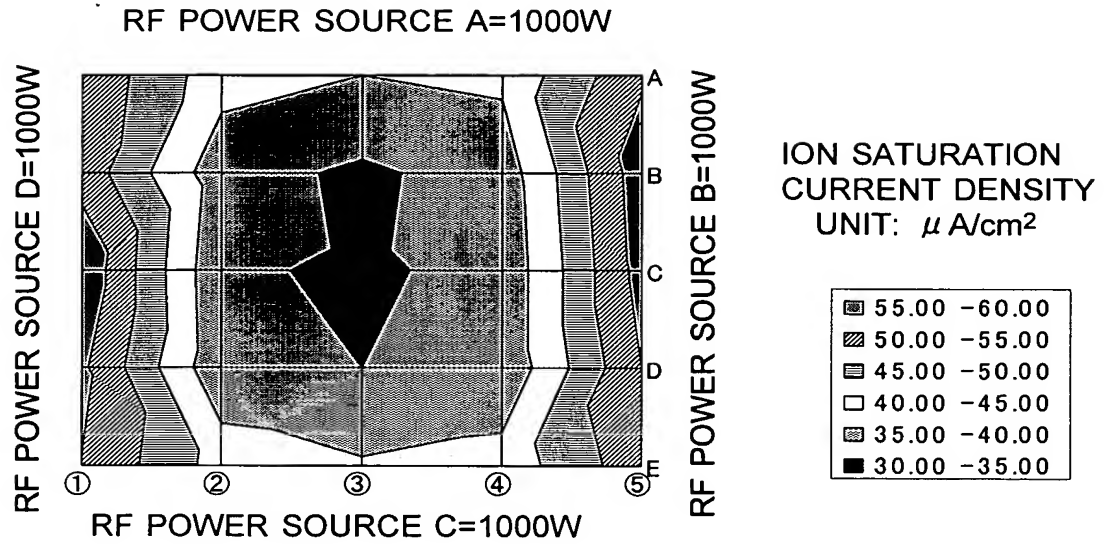


Fig. 5B

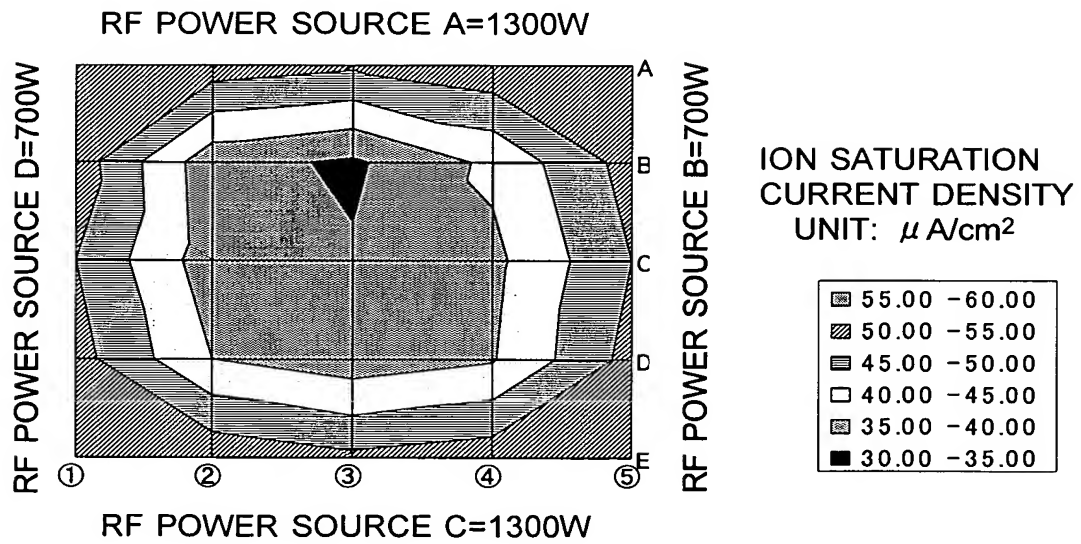


Fig. 6

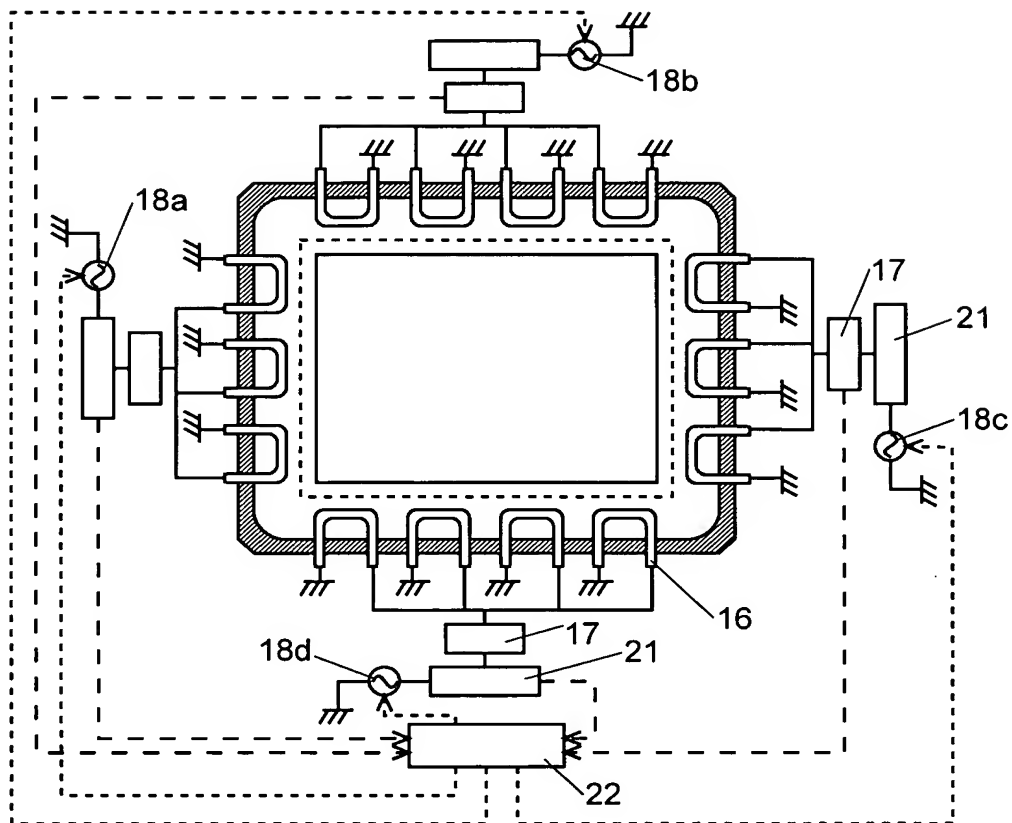


Fig. 7

CHANGE IN PLASMA ELECTRON DENSITY WITH RESPECT TO RF PHASE DIFFERENCE BETWEEN POWER SOURCES

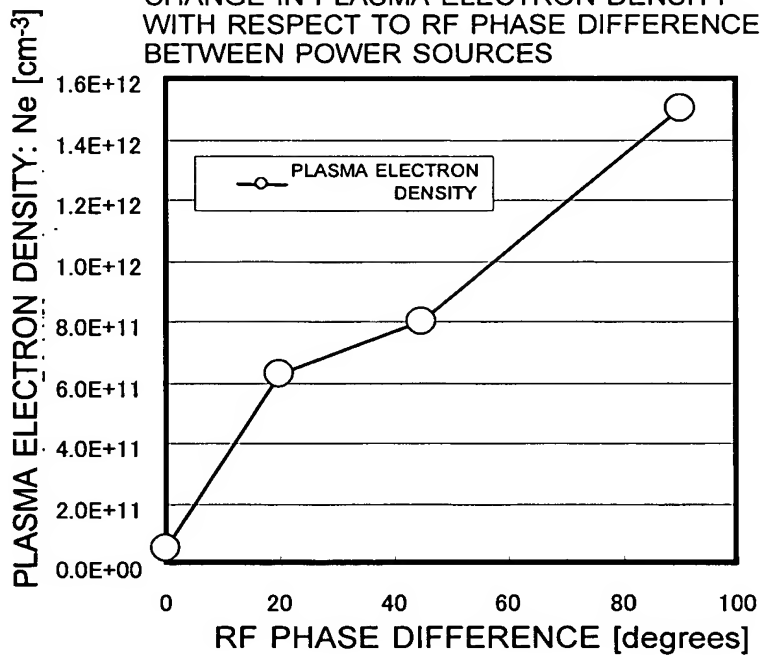


Fig. 8A

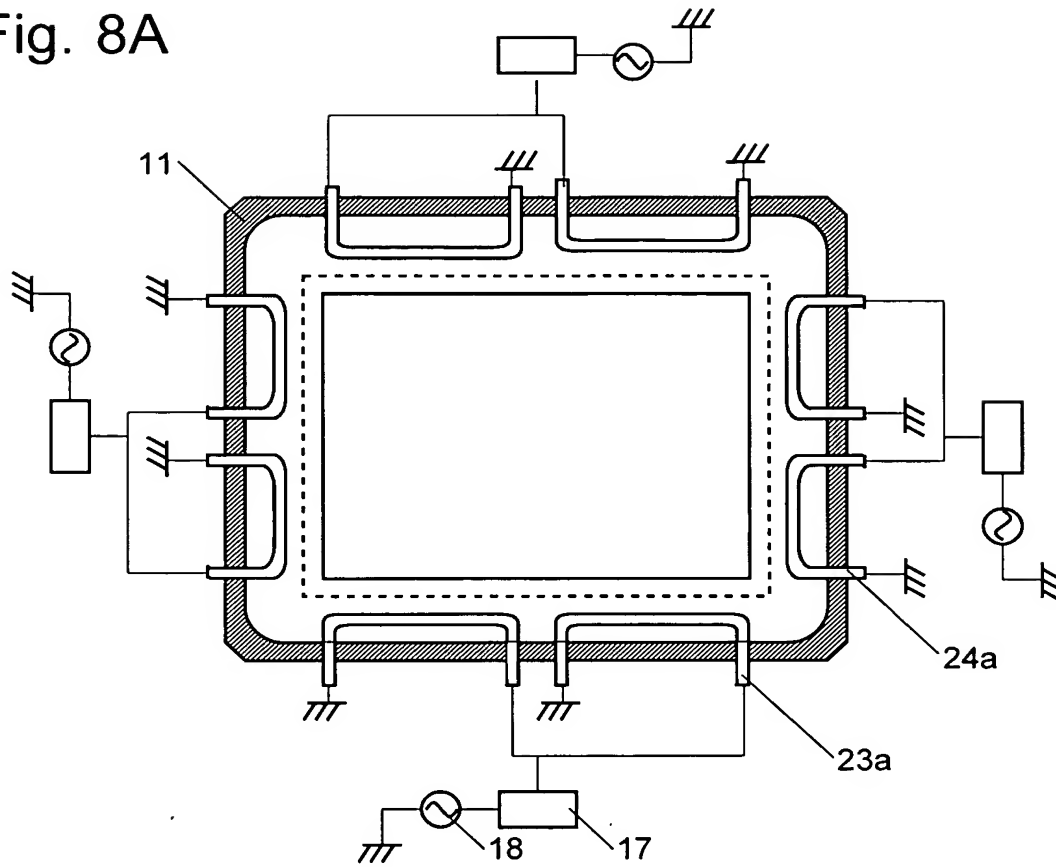


Fig. 8B

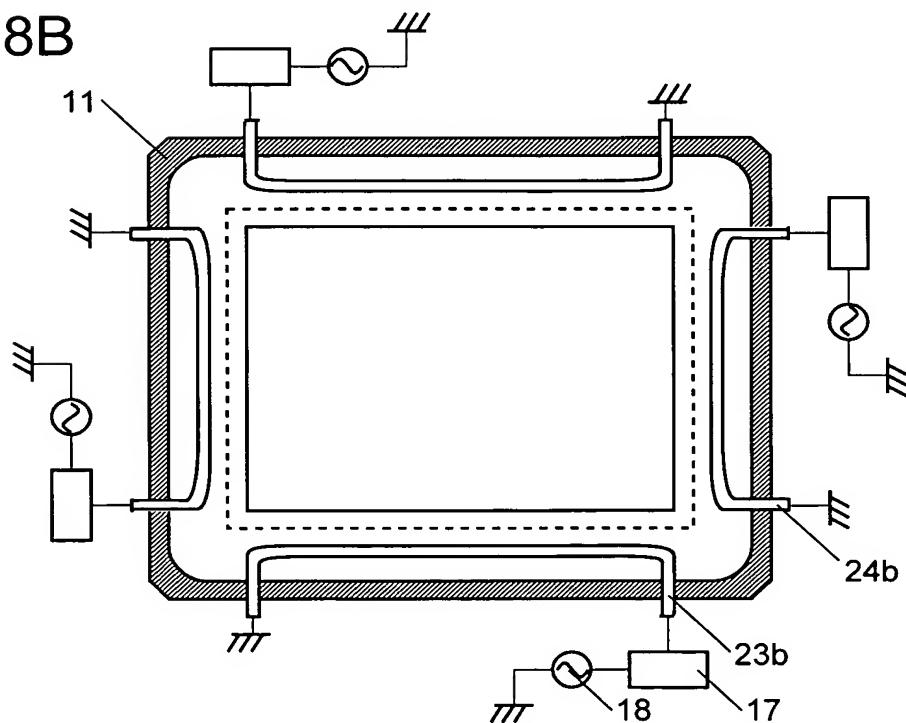


Fig. 9

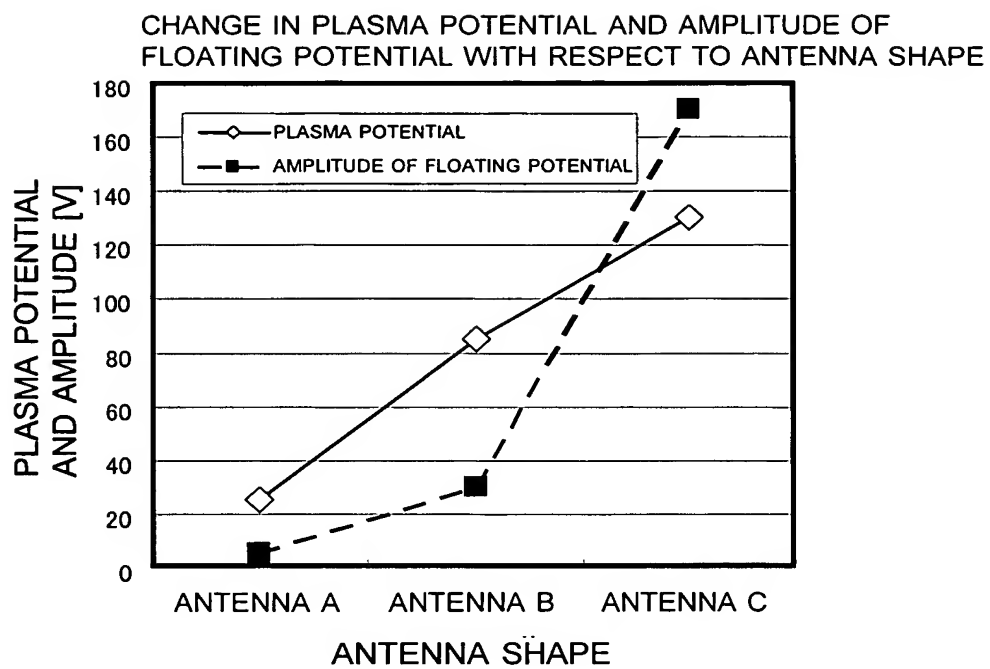


Fig. 10

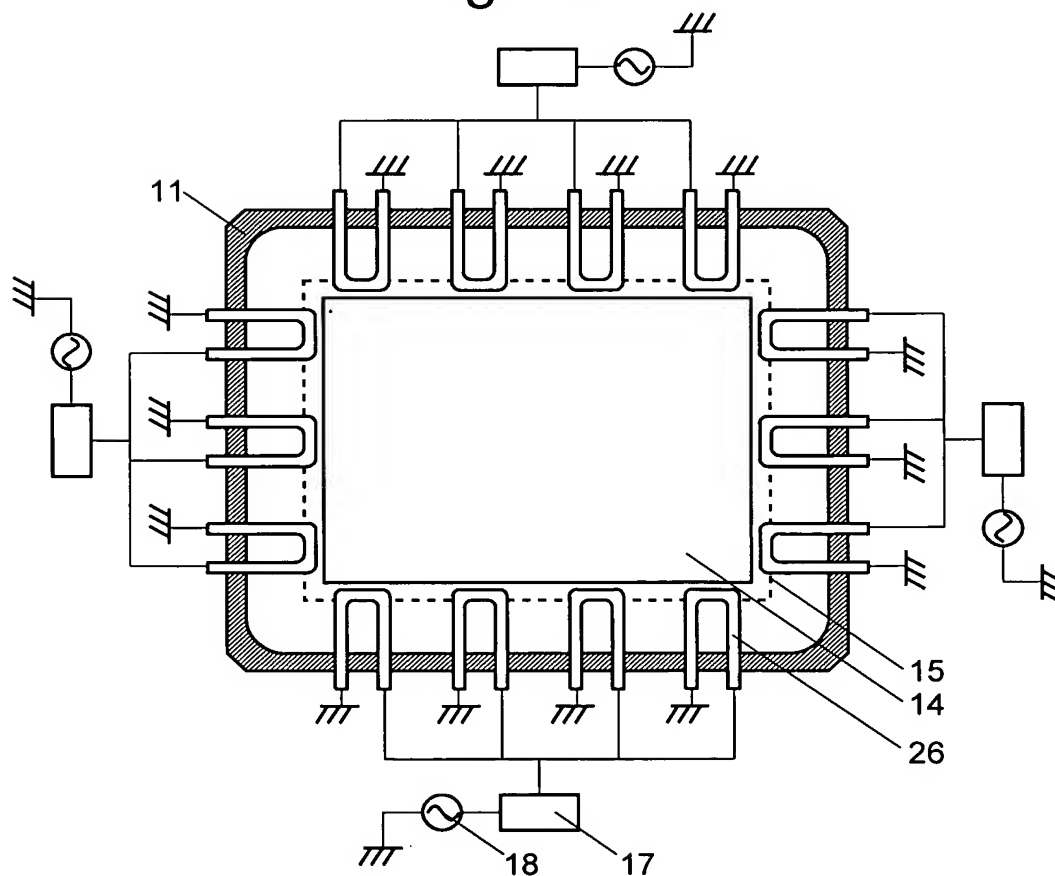


Fig. 11

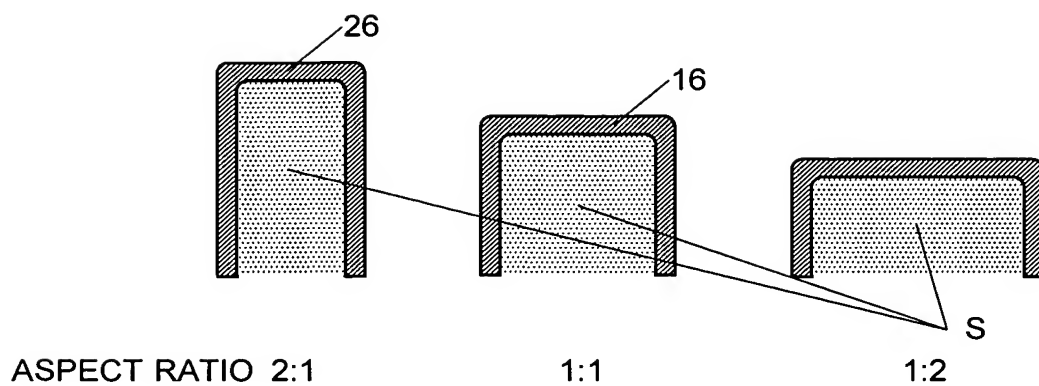


Fig. 12

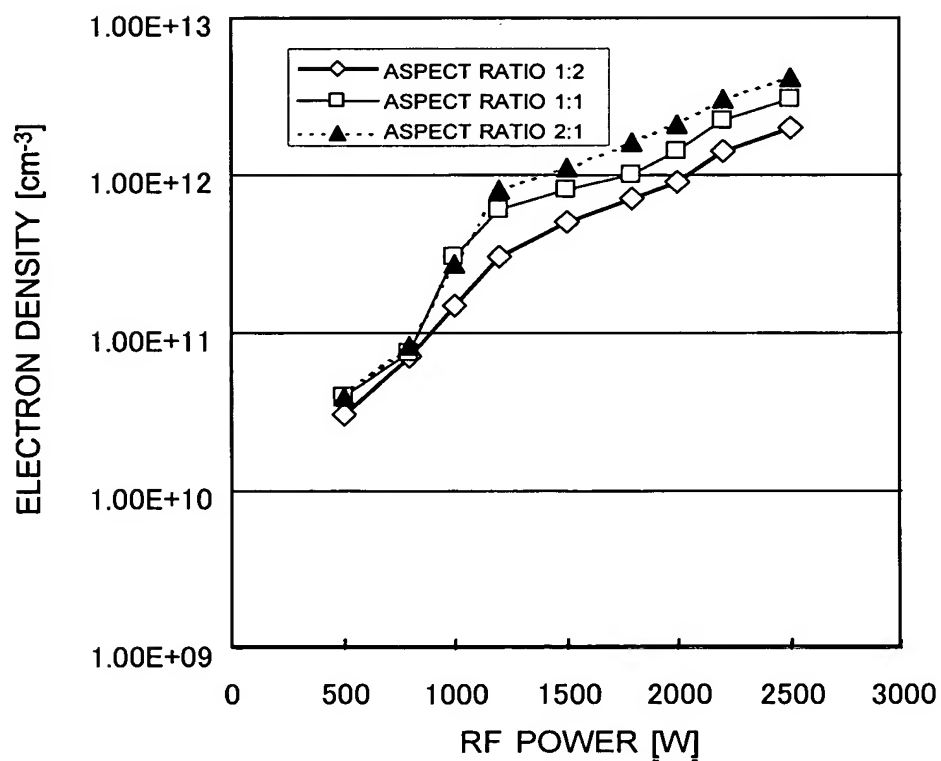




Fig. 15A

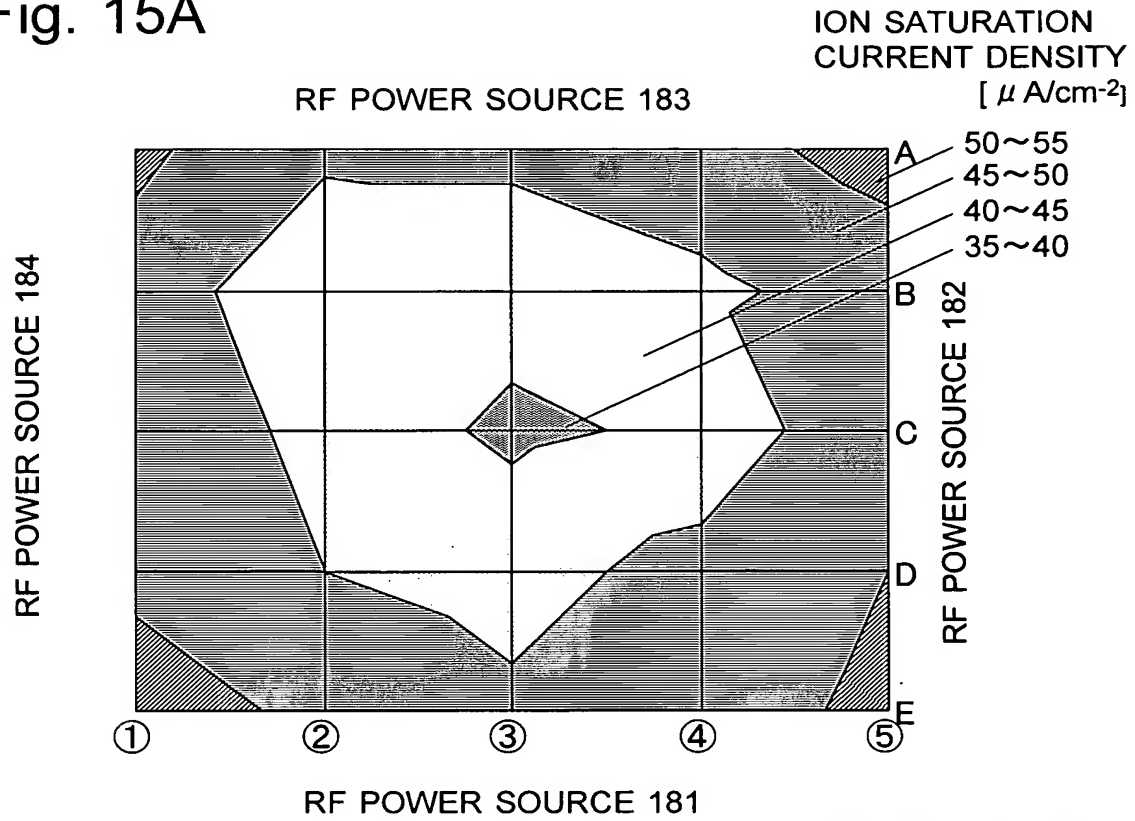
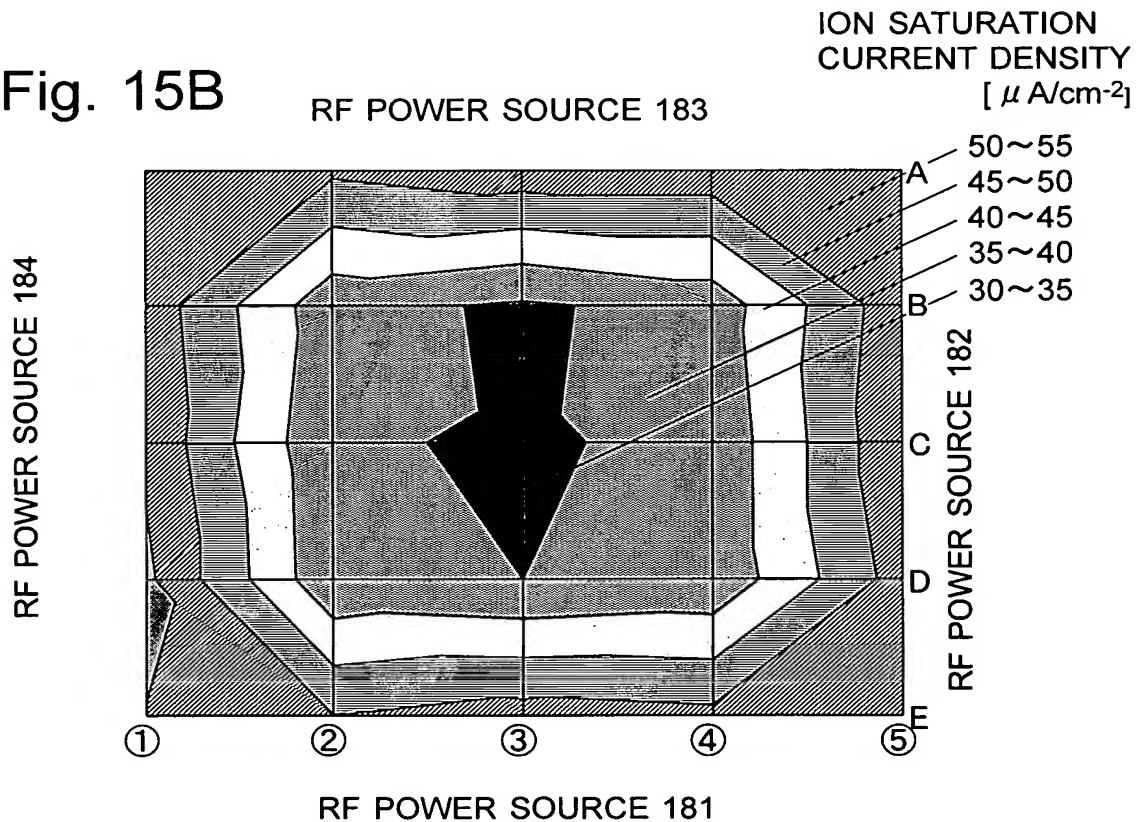


Fig. 15B



A schematic diagram of a magnetic field measurement system. A sample, labeled 32, is positioned vertically between two coils, 16a and 16b. A third coil, 16c, is located below the sample. The coils are connected to a circuit that includes a rectangular block and a circular component. A vertical arrow labeled $V=0$ indicates the magnetic field direction.

Fig. 18

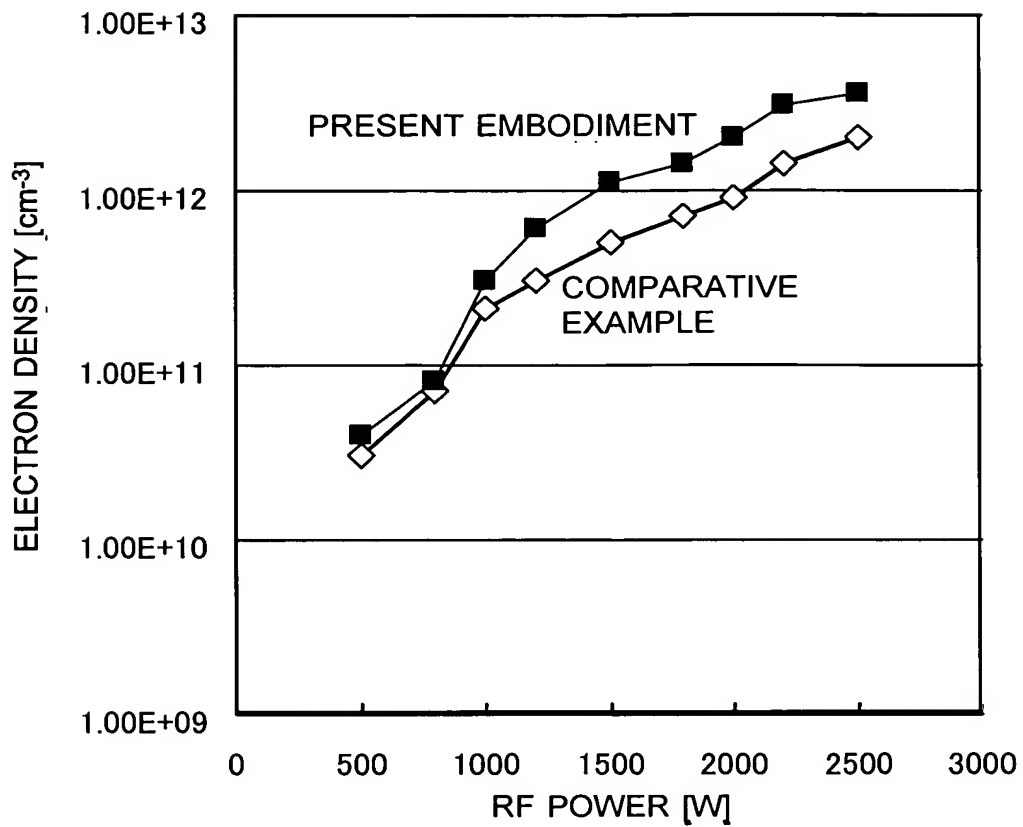


Fig. 19

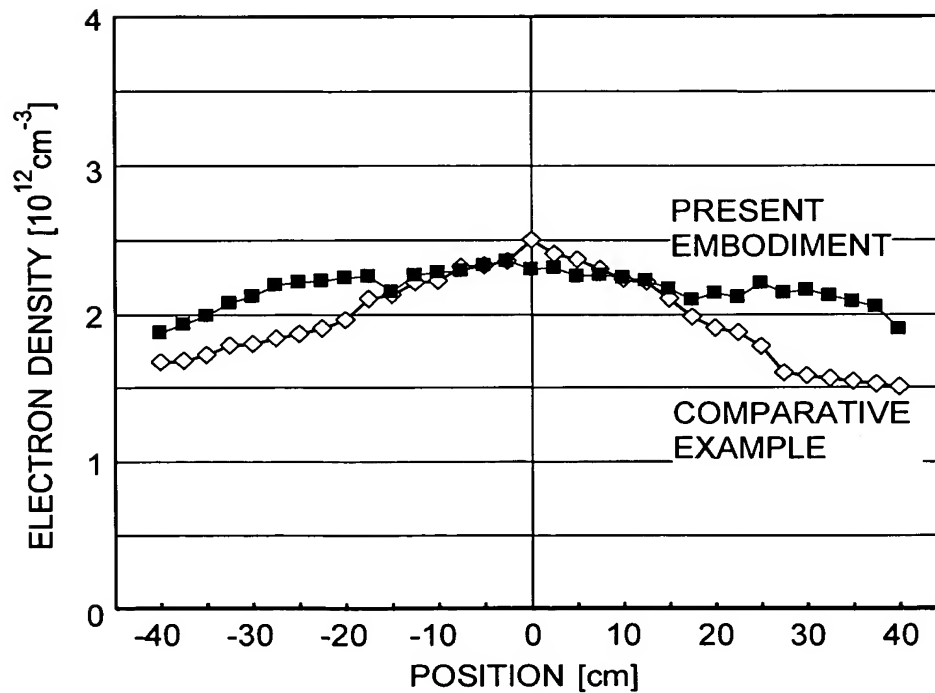


Fig. 20

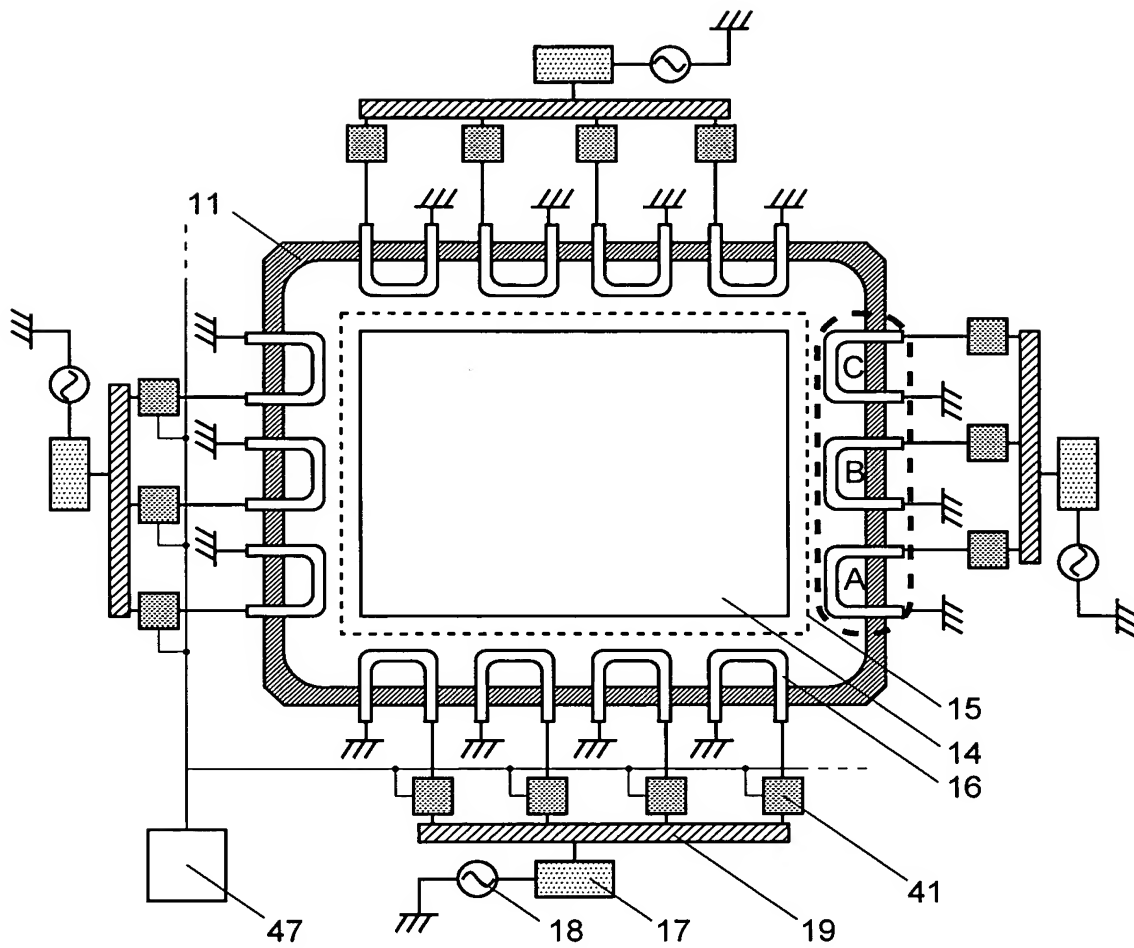


Fig. 21

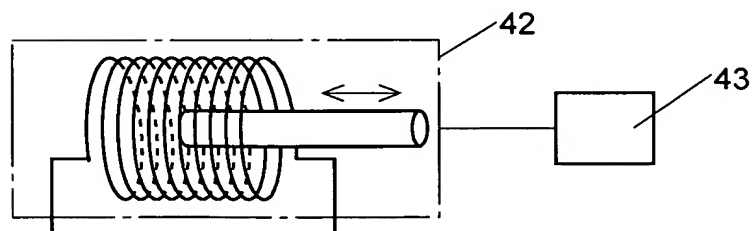


Fig. 22

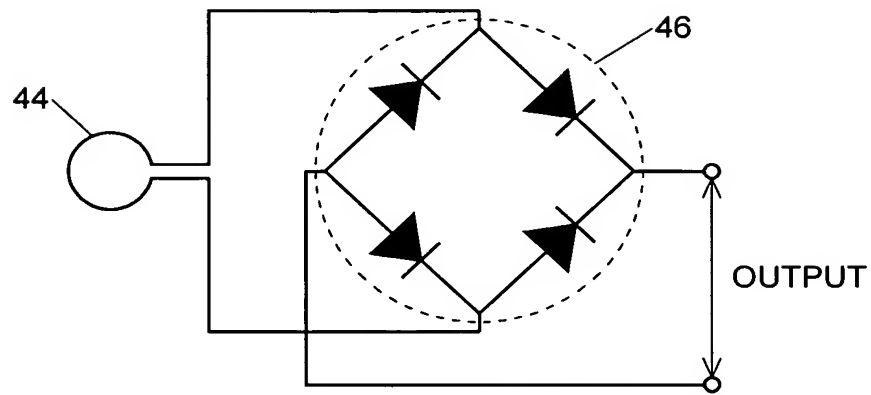


Fig. 23

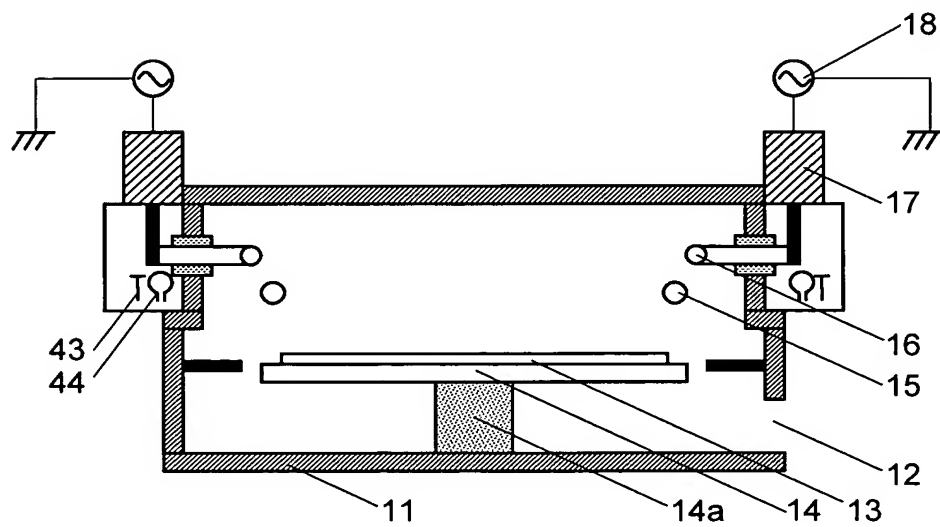


Fig. 24

